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## IN THE UNITED STATES PATENT & TRADEMARK OFFICE

7.57eptor 5/20/03

IN RE APPLICATION OF:

EIJI SAKAGAMI

:EXAMINER: H. WEISS

SERIAL NO.: 09/955,076

FILED: SEPTEMBER 19, 2001

:GROUP ART UNIT: 2814

FOR: NONVOLATILE SEMICONDUCTOR MEMORY

HAVING MONOS STRUCTURE AND METHOD ...

## AMENDMENT UNDER 37 C.F.R. §1.114(c)

ASSISTANT COMMISSIONER FOR PATENTS WASHINGTON, D.C. 20231

SIR:

In response to the Office Action dated November 8, 2002 and Advisory Action dated March 5, 2003, please amend the above-identified patent application as follows:

## IN THE CLAIMS

## Please amend Claim 1 to read as follows:1

- 1. (Twice Amended) A nonvolatile semiconductor memory comprising:
- a semiconductor substrate;
- a first transistor formed on a surface of said semiconductor substrate and including a

first gate insulating film and a first gate electrode;

a second transistor formed on the surface of said semiconductor substrate and including a second gate insulating film and a second gate electrode; and

<sup>&</sup>lt;sup>1</sup>The changes to Claim 1 are denoted using underscoring and bracketing in the marked-up copy herewith.